

Abstract of Disclosure

The present invention discloses a reformed wafer boat. The
5 reformed wafer boat has a plurality of trenches. A first interval is
formed between each trench and one adjacent trench, and a second
interval is formed between each trench and the other adjacent
trench. The wafers placed on the trenches at both ends of the
second interval are in form of back to back, and the first interval is
10 formed between surfaces of each wafers. This kind of design does
not affect uniformity during process, and the throughput can also
be effectively improved.